

Notice of References Cited		Application/Control No. 09/489,356	Applicant(s)/Patent Under Reexamination SHIH ET AL.	
		Examiner Rudy Zervigon	Art Unit 1763	Page 1 of 1

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	B	US-			
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	J	US-			
	K	US-			
	L	US-			
	M	US-			

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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.